Serial No. Atty. Docket No. 10/718.109 034299-548 U.S. Department of Commerce Patent and Trademark Office Applicant: Mazen et al Information Disclosure Statement by Applicant Filed: 11/19/03 Group: Unassigned (Use several sheets if necessary) **U.S. Patent Documents** Filing Date Class Subclass Name Document No. Date Init. Ozturk et al 5,250,452 10/93 Α M. Semeria et al US 2003/0186512 10/03 В Other Documents (Including Author, Title, Date, Pertinent Pages, etc.) Copy of French Search Report, corresponding to French patent application FR 0214658  $\overline{\mathsf{c}}$ M Madhukar, et al "CVD growth of Si nanocrystals on dielectric surfaces for nanocrystal floating gate memory application, Mat. Res. Soc. Symp. Proc. Vol. 638 @ 2001 Material Research Society Fernandes et al, "Memory Characteristics of Si Quantum Dot Devices with SiO<sub>2</sub>/ALD AL<sub>2</sub>O<sub>3</sub> Tunneling Ε **Dielectrics** Mazen et al, "A two Steps CVD process for the growth of Silicon nano-crystals, Applied Surface Science 214 F (2003) 359-363 Schmidt et al, "Self-Assembled Ge/Si Dots for Faster Field-Effect Transistors, IEEE Transactions on Electron Devices, Vol. 48, No. 6, 6-01 Kamins et al, "Lithographic positioning of self-assembled Ge islands on Si(001) © 1997 American Institute fo Baron et al, "Silicon quantum dot nucleation on Si<sub>3</sub> N<sub>4</sub>, SiO<sub>2</sub> and SiO<sub>x</sub> N<sub>y</sub> substrates for nanoelectronic devices, Į Journal of Crystal Growth 209 (2000) 1004-1008 Ishii et al, "Selective Ge deposition on Si using thermal decomposition of GeH4, @ 1985 American Institute of ho Physics Date Considered 3-205 Examiner Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if

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